F rm PTO-1449 LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Us several sh ets if necessary) ATTORNEY DOCKET NO. 10003976-4 APPLICANT Moll et al. FILING DATE TBA GROUP TBA

REFERENCE DESIGNATION

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EXAMINER		DATE CONSIDERED

^{*} C pies f these references are not enclosed Pursuant to 37 CFR 1.98(d). (See accompanying IDS)

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Invent	r(s): Moll et al.	
Serial I	No.: TBA	Examiner: TBA
Filing I	Date: November 12, 2003	Group Art Unit: 0
	THIN GALLIUM ARSENIDE ANTIMONIDE BASE HETEROJ G IMPROVED GAIN	UNCTION BIPOLAR TRANSISTOR (HBT)
P.O. B	ISSIONER FOR PATENTS ox 1450 adria VA 22313-1450	
Sir:	INFORMATION DISCLOSURE S	<u>TATEMENT</u>
This Inf	formation Disclosure Statement is submitted:	•
(a) 🛚	Under 37 CFR 1.97(b). (Within three months of filing national application; or date of entry of nation on the merits; whichever occurs last).	al application; or before mailing date of first Office action
(b) 🗌	Under 37 CFR 1.97(c) together with <i>either</i> a: Statement under CFR 1.97(e), or \$\int\\$ \$180.00\$ fee under 37 CFR 1.17(p). (After the CFR 1.97(b) time period, but before a final action or notice of allows)	owance, whichever occurs first).
(c) 🗌	Under 37 CFR 1.97(d) together with: a Statement under 37 CFR 1.97(e), <i>and</i> \$180.00 fee as set forth in 37 CFR 1.17(p). (After a final action or notice of allowance, whichever occurs first, but befo	re payment of the issue fee).
commuthe filin from a making	TATEMENT UNDER 37 CFR 1.97(e) dersigned certifies that: Each item of information contained in the Information Distriction from a foreign patent office in a counterpart foreign g of the statement, or No item of information contained in the Information Distriction patent office in a counterpart foreign application, and preasonable inquiry, was known to any individual designated the filing of the Information Disclosure Statement.	application not more than three months prior to closure Statement was cited in a communication to the knowledge of the undersigned after
Referen Applica	RIOR APPLICATIONS nces identified with an asterisk (*) in the enclosed PTO Form tion No. 9796299, filed February 27, 2001, now U.S. Patent d pursuant to the provisions of 37 CFR 1.98(d).	
other for designation foreign application	PREIGN LANGUAGE DOCUMENTS A concise explanation of the relevance of foreign language oreign language information listed on PTO form 1449, as presented in 37 CFR 1.56(c) most knowledgeable about the content language patent is cited in a search report or other action by tion, an English language version of the search report or action by the foreign office is listed on form PTO 1449 and is enclosed.	sently understood by the individual(s) It is given on the attached sheet, or where a a foreign patent office in a counterpart foreign on which indicates the degree of relevance

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Reg. No. 41,344

Date: November 12, 2003

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